

AF

In re application of

Confirmation No. 1092

Hiroto YUKAWA et al.

Attorney Docket No. 2004\_0499

Serial No. 10/810,902

Group Art Unit 1752

Filed March 29, 2004

Examiner Sin J. Lee

POSITIVE-WORKING CHEMICAL-AMPLIFICATION PHOTORESIST COMPOSITION Mail Stop: AF

## **RESPONSE TO FINAL REJECTION**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In Response to the Final Rejection dated July 12, 2006, please amend the present application as follows:

Please Enter S.J.L. 9/11/06